Polarity Inversion in Polar-Nonpolar-Polar Heterostructures

Sunglæ Cho

Department of Physics, University of Ulsan, Ulsan, 680-749, South Korea

Suk J. Youn, Yunky Kim, Antonio DiVenere, George K. L. Wong,* Authur J. Freeman, and J. B. Ketterson †

Department of Physics and Astronomy, Northwestern University, Evanston, Illinois 60208

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We have observed an epilayer-thickness-dependent polarity inversion for the growth of CdTe on Sb(Bi)/CdTe(111)B. For films with Sb(Bi) thicknesses of less than 40 Å (15 Å), the CdTe layer shows a B (Te-terminated) face, but it switches to an A (Cd-terminated) face for thicker layers. On the other hand, a CdTe layer grown on Bi(Sb)/CdTe(111)A always shows the A face regardless of Sb or Bi layer thicknesses. In order to address the observations we have performed ab initio calculations, which suggest that the polarity of a polar material on a nonpolar one results from the binding energy difference between the two possible surface configurations.

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The zinc-blende (wurtzite) crystal structure is noncentrosymmetric, leading to nonequivalent (111) [(001)] vs (TTT) [(00T)] planes, which is referred to as surface polarity. For example, the A face for CdTe(111) is terminated by Cd atoms, while the B face is terminated by Te. The chemical and physical properties of various epilayers strongly depend on the surface configuration [1–21]. For example, Ga-terminated GaN films show atomically flat surfaces, whereas N-terminated epilayers generate a rough surface morphology with high defect densities [1–17]. In CdTe(111), the Te-terminated face shows a smooth surface, whereas the Cd-terminated face is rough [20]. On the other hand, epitaxial growth of a nonpolar material on polar surfaces shows interesting differences compared to growth on nonpolar surfaces. For example, the growth mode [22–25] and surface reconstruction are quite different depending upon whether growth was started on the A or B surfaces. α-Sn thin films grow with a biatomic layer-by-layer mode on InSb(111)A and with a more complicated layerlike mode accompanied by Sb segregation on InSb(111)B [25]. Bi grows in a layer-by-layer mode on CdTe(111)B, but exhibits 3D island growth on (111)A until 40 Å, thereafter coalescing [22–24]. Thus, surface polarity selection and control of the epilayer is a key issue in obtaining high-quality polar thin films with smooth morphology and low defect density. In this Letter, we report the observation of polarity inversion; the case in point involves the growth of CdTe on Sb(Bi)/CdTe(111)B. For films with Sb(Bi) thicknesses of less than 40 Å (15 Å), the CdTe shows a B (Te-terminated) face, whereas above these thicknesses an A (Cd-terminated) face is observed. On the other hand, a CdTe layer grown on Bi(Sb)/CdTe(111)A always shows the A face, regardless of Sb or Bi layer thicknesses. Based on experimental and first principles band structure data for CdTe(111)/Sb(Bi)/CdTe(111) systems, we demonstrate that the polarity of a polar material on a nonpolar one is determined from the binding energy difference between the two possible surface configurations. Thus, the polarity of the top polar layer relative to the bottom polar layer can sometimes be flipped by inserting an ultrathin second material.

We used a custom-built molecular beam epitaxy system to deposit the epilayers which is similar to a Varian Model 360; it consists of growth, analysis, and load-lock chambers and is equipped with reflection high-energy electron diffraction (RHEED) and Auger electron spectroscopy as described elsewhere [22,23]. The base pressure of the growth chamber was in the 10–10 Torr range. The CdTe(111)A/B substrates were etched in a solution of 2% bromine in methanol. After thermal annealing at 300 °C for 30 min, we deposited a 3000 Å CdTe buffer layer on the CdTe substrate at 250 °C, resulting in the preparation of a smooth surface. The Sb or Bi layers were deposited at a rate of ≈0.3 Å/s and at a temperature of 150 °C. The crystal structure of Sb and Bi is rhombohedral, and the growth direction on CdTe(111) is parallel to the trigonal axis. The in-plane lattice mismatches of Sb (a = 4.308 Å) and Bi (a = 4.546 Å) with CdTe(111) (a = 4.58 Å) are 5.9% and 0.7%, respectively, in the hexagonal setting. RHEED has been used to identify the specific surface reconstruction, growth mode of the deposited layers, and the polarity of the as-grown top CdTe films.

The polarity of CdTe(111) results in a differing growth mode of Bi on the A and B faces of CdTe(111) (the A face is terminated by Cd atoms, while the B face is terminated by Te atoms). Bi on the A face displays 3D-island growth during the first 40 Å, thereafter coalescing, while Bi on the B face grows layer-by-layer [22,23]. These differing behaviors were exploited as an in situ method of determining the polarity of CdTe; the polarities were confirmed with etch pit experiments [using Nakagawa solution (HF; H2O2:H2O = 3:2:3 v/v)], which yields etch pits on the (111)A faces and untouched B faces, and the known surface reconstruction differences between A and B faces of CdTe (observed by RHEED) [22].
In our earlier studies [22–24], we also showed that CdTe(111) growth on thick (nonpolar) Sb or Bi [on α-Al2O3 or CdTe(111)A/B substrates] starts with Te and ends with Cd, resulting in a (111)A surface. If we deposit Sb or Bi on CdTe(111)B followed by CdTe, the Te planes in both CdTe layers face the Sb or Bi layers, provided that the intermediate layer is not too thin. It is of interest to examine the polarity of the CdTe overlayer as the intermediate semimetal layer thickness goes to zero. Clearly, the polarity of the CdTe overlayer must change from A to B in the limit of zero thickness. We have investigated the polarity of the CdTe overlayer for varying intermediate semimetal layer thickness.

Figures 1(a) and 1(b) show the (1T0) azimuth RHEED patterns of a 3000 Å CdTe(111)B buffer layer and after a 5 Å Sb layer subsequently grown. The CdTe(111)B face has a $2\sqrt{3} \times 2\sqrt{3}$-R30° surface reconstruction. Sb on the CdTe(111)B showed no surface reconstruction and streaky patterns, representing layer-by-layer growth of Sb. Figure 1(c) shows the RHEED pattern of 150 Å of CdTe(111) on 5 Å Sb/CdTe(111)B. The patterns resulting from depositing a 15 Å Bi layer on 150 Å CdTe/5 Å Sb/CdTe(111)B is streaky, as shown in Fig. 1(d), indicating a B face for the top CdTe layer. When the intermediate Sb layer thickness was increased to 35 Å, the B face was also observed [Fig. 1(e)]. However, the RHEED pattern of Bi on 150 Å CdTe/50 Å Sb/CdTe(111)B shows a spotty pattern [Fig. 1(f)], representing a 3D-island growth of Bi and an A face for the top CdTe layer. The Sb critical thickness for the polarity inversion from the B to the A of CdTe on Sb/CdTe(111)B is therefore around 40 Å. On the other hand, in the case of CdTe(111)A substrates, the polarity of the top CdTe layer always remains A face, regardless of the intermediate Sb layer thickness, as shown in Figs. 1(g) and 1(h). Note Sb grows layer-by-layer on either the A or the B face of CdTe(111).

When Bi is substituted for Sb, we have observed similar results except the critical thickness ($\sim$15 Å) for the polarity inversion is smaller. Results similar to ours have been observed by Omi et al. [25]: InSb on α-Sn(111)/InSb(111)B changes its surface polarity with α-Sn thickness. Below 20 Å of α-Sn, the InSb exhibits the B face (Sb-terminated), whereas above this thickness InSb becomes A face (In-terminated). InSb on α-Sn(111)/InSb(111)A always shows an A face. In Table I we summarized our results as well as the literature result for the α-Sn/InSb case. The polarity of CdTe grown on Sb or Bi is A face, independent of the polarity of the CdTe(111) substrate, except when the Bi or Sb thickness falls below the critical thickness. Below this critical thickness, the polarity of CdTe grown on Sb(Bi)/CdTe(111)B changes to A face.

In order to explore why the Te face attaches to nonpolar Sb or Bi, we performed an electronic structure calculation using the full-potential linearized augmented plane wave method which does not impose any shape approximation on the potential. This particular code is adapted to calculate the electronic properties of a “slab” of a specified number of layers and stacking sequences. The total energies for the two cases in which Te is adjacent to Sb and Cd is adjacent to Sb were calculated for a Cd-Te(Te-Cd) layer on four Sb layers. We assumed the bulk electronic structure for the fourth Sb layer from the interface and used the in-plane

![RHEED patterns](image)

**FIG. 1.** RHEED patterns of (a) of CdTe(111)B buffer (1T0) azimuth; (b) 5 Å Sb on CdTe(111)B; (c) 150 Å CdTe grown on 5 Å Sb/CdTe(111)B; (d) 15 Å Bi grown on 150 Å CdTe/5 Å Sb/CdTe(111)B; (e) 15 Å Bi grown on 150 Å CdTe/35 Å Sb/CdTe(111)B; (f) 15 Å Bi grown on 150 Å CdTe/50 Å Sb/CdTe(111)B; (g) 15 Å Bi grown on 150 Å CdTe/5 Å Sb/CdTe(111)B; and (h) 15 Å Bi grown on 150 Å CdTe/50 Å Sb/CdTe(111)A.

<table>
<thead>
<tr>
<th>Substrate</th>
<th>Intermediate layer</th>
<th>Polarity of top layer</th>
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<tbody>
<tr>
<td>CdTe(111)B</td>
<td>&gt;40 Å Sb or 15 Å Bi</td>
<td>CdTe(111)A</td>
</tr>
<tr>
<td></td>
<td>&lt;40 Å Sb or 15 Å Bi</td>
<td>CdTe(111)B</td>
</tr>
<tr>
<td>CdTe(111)A</td>
<td>Sb or Bi</td>
<td>CdTe(111)A</td>
</tr>
<tr>
<td>InSb(111)B</td>
<td>&gt;20 Å α-Sn</td>
<td>InSb(111)A</td>
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<td>&lt;20 Å α-Sn</td>
<td>InSb(111)B</td>
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<td>InSb(111)A</td>
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lattice constant of bulk Sb. Relaxation was included along the (111) direction by means of atomic force calculations. The calculated total binding energy of an Sb-Te pair is 16 meV lower than that for an Sb-Cd pair [26]. This result implies that a Sb-Te pair is energetically more favorable than a Sb-Cd pair, resulting in the initial Te layer growth on Sb or Bi and ending with a Cd layer (i.e., A face). Therefore, it is not surprising that a CdTe layer grown on thick Sb(Bi)/CdTe(111)B exhibits the A face. In this case, the Te atom layers in both CdTe layers (top layer and substrate) are facing the Sb or Bi layer.

In order to further investigate the above system, we calculated the charge density and charge transfer near the Sb-Te interface as shown in Figs. 2(a) and 2(b), respectively. We can clearly see the chemical bonding between the CdTe and Sb layers. A charge transfer plot shows that more electrons accumulate near the Te site than the Cd site. This indicates that, while the bonding is mostly covalent, there is a small ionic character between Cd and Te atoms, which possibly results in a surface polarization.

As mentioned earlier, the initial Te layer growth on thick Sb(Bi) is due to stronger Sb(Bi)-Te bonding as opposed to Sb(Bi)-Cd bonding, resulting in A-face termination [Fig. 3(a)]. In this case, the Te layers in both CdTe layers face the Sb(Bi) layers. The polarity inversion on ultrathin Sb(Bi)/CdTe(111)B indicates the presence of another mechanism which overcomes the binding energy difference between Sb(Bi)-Te and Sb(Bi)-Cd. Based on the facts that the polarity of the CdTe overlayer on CdTe(111)B must change from A to B in the limit of zero intermediate layer thickness, and that a small ionic character between Cd and Te atoms possibly induces a surface polarization, we suggest that this second mechanism may involve the additional electrostatic interaction arising from the surface induced polarization, as illustrated in Fig. 3, whose direction is downward and upward for the B and the A faces of the CdTe substrate, respectively. In the case of the CdTe(111)A/thick Sb(Bi)/CdTe(111)B system [Fig. 3(a)], the direction of the two polarizations is opposite, which may result in a repulsive force. However, when the distance between the two polar layers is large, this interaction will be negligible due to electrostatic screening. As the Sb or Bi layer thickness decreases, the interaction will increase, and eventually the polarity inverts in order to minimize this electrostatic interaction energy.

Thus, polarity inversion is expected when

\[ E_{p-p} \geq \Delta E_b \]

where \( E_{p-p} \) is the electrostatic interaction energy between the top layer and the substrate, and \( \Delta E_b \) is the binding energy difference between Sb(Bi)-Te and Sb(Bi)-Cd interfaces. The differing critical thickness for Sb and Bi intermediate layers may be correlated with a binding energy difference, different dielectric constants, and the strength of conduction electron screening. Similarly, we can apply this model to an A-face substrate. In the case of a CdTe(111)A substrate with both thin and thick Sb(Bi) layers, the two polarizations are parallel [Fig. 3(b)]; i.e., the interaction energy is lower, and the above relation is not satisfied. Therefore, as the intermediate Sb(Bi) layer thickness decreases the polarity does not change, as observed. This model may also apply to the InSb/α-Sn/InSb system.

In conclusion, we have observed a polarity inversion of the CdTe top layer on Sb(Bi)/CdTe(111)B with ultrathin Sb or Bi layer thicknesses: For films with Sb(Bi) thicknesses of less than 40 Å (15 Å), the CdTe shows a B (Te-terminated) face, whereas above these thicknesses an A face.

![FIG. 2. (a) The charge density and (b) the charge transfer for a CdTe layer on Sb near the Te-Sb interface in the (110) plane. In (a), we can see chemical bonding at the CdTe and Sb interfaces. The charge transfer is defined by \( \Delta \rho = \rho_{CdTe/Sb} - \rho_{CdTe} - \rho_{Sb} \), where \( \rho_{CdTe/Sb} \), \( \rho_{CdTe} \), and \( \rho_{Sb} \) are the charge densities of CdTe/Sb, Cd monolayer, the Te monolayer, and the Sb layers, respectively. In (b), the solid and dotted lines represent a charge accumulation and depletion, respectively.](attachment:image1.png)

![FIG. 3. Schematic views of the polarity properties of CdTe(111) grown on (a) CdTe(111)B and (b) CdTe(111)A with Sb(Bi) intermediate layers. P represents the surface induced polarization. For a thick Sb or Bi layer on CdTe(111)B, the polarity of a CdTe overlayer is A; i.e., the two surface polarizations are opposite. Below the critical thickness of Sb(Bi) on CdTe(111)B, the polarity of the CdTe overlayer changes from A to B due to the repulsive electrostatic interaction. The polarity of a CdTe overlayer on Sb(Bi)/CdTe(111)A is A regardless of the thickness of the semimetal layer because the two polarizations are always parallel.](attachment:image2.png)
(Cd-terminated) face is observed. Our results indicate that the polarity of a polar material on a nonpolar one is determined by the binding energy difference of the two different surface configurations and can be controlled by modifying substrate surface states, e.g., by inserting an ultrathin second species. This “polarity engineering” should prove to be very useful in fundamental surface-related studies as well as in the device-design arena: e.g., for fabricating phase matched waveguides for second harmonic generation [27] or microwave/infrared multilayer acoustic transducers [28].

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*Permanent address: Physics Department, HKUST, Clearwater Bay, Kowloon, Hong Kong.
†Also at Department of Electrical and Computer Engineering.